

Certificate of Approval

This is to certify that the Management System of:

EPSRC National Epitaxy Facility

Centre for Nanoscience and Technology, University of Sheffield, Broad Lane, Sheffield, S3 7HQ,
United Kingdom

has been approved by LRQA to the following standards:

ISO 9001:2015

Approval number(s): ISO 9001 – 00032973

The scope of this approval is applicable to:

Design, research and production/growth of compound semiconductor wafers on MBE and MOVPE (As, P based) growth reactors at Sheffield University. Including the design and fabrication of semiconductor devices in support of epitaxy growth and testing of products. Including collaboration with customers through pump priming to increase the Facility's capability to meet future requirements. This quality management system is implemented at the request of the Engineering Physical Sciences Research Council (EPSRC), to ensure the National Epitaxy Facility continues to improve its service in supplying the UK universities research community with high quality semiconductor materials.

David Derrick

Regional Director, UKAM

Issued by: LRQA Limited

